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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



Applicants: S. SHUKURI, et al.  
Application. No. 10/635,511  
Filed: August 7, 2003  
For: SEMICONDUCTOR INTEGRATED CIRCUIT DEVICE HAVING  
DEPOSITED LAYER FOR GATE INSULATION  
Group: 2814  
Examiner: Long Pham  
Confirm. No.: 8446

**AMENDMENT AFTER FINAL REJECTION**

Mail Stop: AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

November 23, 2005

Sir:

In response to the Office Action mailed August 24, 2005, please amend the above-identified application as listed in the following, and as set forth on the following pages:

AMENDMENTS TO THE CLAIMS; and

REMARKS are included following the amendments.